Toru Akiyama

List of Publications by Year in descending order

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ΤΟΡΗ ΔΕΙΧΑΜΑ

#	Article	IF	CITATIONS
1	Structural analysis of polarity inversion boundary in sputtered AIN films annealed under high temperatures. Japanese Journal of Applied Physics, 2019, 58, SCCB30.	1.5	13
2	Structures and Polarity of Illâ€Nitrides: Phase Diagram Calculations Using Absolute Surface and Interface Energies. Physica Status Solidi (B): Basic Research, 2018, 255, 1700329.	1.5	10
3	Absolute surface energies of semipolar planes of AlN during metalorganic vapor phase epitaxy growth. Journal of Crystal Growth, 2019, 510, 7-12.	1.5	9
4	Ab initio study for adsorption and desorption behavior at step edges of AlN(0001) and GaN(0001) surfaces. Japanese Journal of Applied Physics, 2020, 59, SGGK03.	1.5	9
5	Effect of Step Edges on Adsorption Behavior for GaN(0001) Surfaces during Metalorganic Vapor Phase Epitaxy: An <i>Ab Initio</i> Study. Crystal Growth and Design, 2020, 20, 4358-4365.	3.0	8
6	Effects of lattice constraint on structures and electronic properties of BAIN and BGaN alloys: A first-principles study. Applied Physics Express, 2018, 11, 025501.	2.4	7
7	Reaction mechanisms at 4H-SiC/SiO ₂ interface during wet SiC oxidation. Japanese Journal of Applied Physics, 2018, 57, 04FR08.	1.5	7
8	Bandgap engineering of α-Ga2O3 by hydrostatic, uniaxial, and equibiaxial strain. Japanese Journal of Applied Physics, 2022, 61, 021005.	1.5	7
9	Recent Progress in Computational Materials Science for Semiconductor Epitaxial Growth. Crystals, 2017, 7, 46.	2.2	6
10	Effects of surface and twinning energies on twining-superlattice formation in group III–V semiconductor nanowires: a first-principles study. Nanotechnology, 2019, 30, 234002.	2.6	6
11	Ab initio calculations for the effect of wet oxidation condition on the reaction mechanism at 4H–SiC/SiO ₂ interface. Japanese Journal of Applied Physics, 2020, 59, SMMD01.	1.5	6
12	Systematic Theoretical Investigations for Crystal Structure Deformation in Groupâ€III Nitrides: A Firstâ€Principles Study. Physica Status Solidi (B): Basic Research, 2018, 255, 1700446.	1.5	5
13	An ab initio approach to polarity inversion of AlN and GaN films on AlN\$(000ar{1})\$ substrate with Al overlayers: an insight from interface energies. Japanese Journal of Applied Physics, 2018, 57, 098001.	1.5	4
14	Realization of honeycomb structures in octet A N B8â^'N binary compounds under two-dimensional limit. Applied Physics Express, 2019, 12, 125501.	2.4	4
15	Computational discovery of stable phases of graphene and h-BN van der Waals heterostructures composed of group III–V binary compounds. Applied Physics Letters, 2021, 118, .	3.3	4
16	Theoretical investigations on the growth mode of GaN thin films on an AlN(0001) substrate. Japanese Journal of Applied Physics, 2019, 58, SC1009.	1.5	2
17	Reaction of NO molecule at 4H-SiC/SiO2 interface: an ab initio study for the effect of NO annealing after dry oxidation. Japanese Journal of Applied Physics, 2021, 60, SBBD10.	1.5	2
18	A Simple Approach to Growth Mode of InN and InGaN Thin Films on GaN(0001) Substrate. ECS Transactions, 2020, 98, 155-164.	0.5	2

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19	Thermodynamic analysis for nonpolar III-nitride surfaces under metalorganic vapor-phase epitaxy conditions. Japanese Journal of Applied Physics, 2020, 59, 028003.	1.5	2
20	<i>Ab initio</i> -based approach for the oxidation mechanisms at <mml:math xmlns:mml="http://www.w3.org/1998/Math/MathML"><mml:msub><mml:mi>SiO</mml:mi><mml:mn>2/4H-SiC interface: Interplay of dry and wet oxidants during interfacial reaction. Physical Review Materials, 2021, 5, .</mml:mn></mml:msub></mml:math 	:mn> 2.4	nl:msub>
21	Ab initio study for orientation dependence of nitrogen incorporation at 4H-SiC/SiO ₂ interfaces. Japanese Journal of Applied Physics, 2022, 61, SH1002.	1.5	2
22	Roles of growth kinetics on GaN non-planar facets under metalorganic vapor phase epitaxy condition. Applied Physics Express, 2020, 13, 065505.	2.4	1
23	Effect of Film Thickness on Structural Stability for BAIN and BGaN Alloys: Bondâ€Order Interatomic Potential Calculations. Physica Status Solidi (B): Basic Research, 2020, 257, 2000205.	1.5	1
24	Effects of Wet Ambient on Dry Oxidation Processes at 4H-SiC/SiO2 Interface: An Ab Initio Study. ECS Transactions, 2020, 98, 37-46.	0.5	1
25	An ab initio-based approach for the formation of pyramidal inversion domain boundaries in highly Mg-doped GaN. Japanese Journal of Applied Physics, 0, , .	1.5	1
26	Influence of oxygen-related defects on the electronic structure of GaN. Japanese Journal of Applied Physics, 2022, 61, 061004.	1.5	1
27	Effective approach for calculating individual energy of step edges on polar AlN(0001) and GaN(0001) surfaces. Japanese Journal of Applied Physics, 2021, 60, 080701.	1.5	0
28	Effects of Wet Ambient on Dry Oxidation Processes at 4H-SiC/SiO ₂ Interface: An Ab Initio Study. ECS Meeting Abstracts, 2020, MA2020-02, 1354-1354.	0.0	0
29	A Simple Approach to Growth Mode of InN and InGaN Thin Films on GaN(0001) Substrate. ECS Meeting Abstracts, 2020, MA2020-02, 1831-1831.	0.0	0
30	Computational Prediction for Stable Structures of Graphene Van Der Waals Heterostructures Composed of Group-III-V Compounds. ECS Meeting Abstracts, 2020, MA2020-02, 1120-1120.	0.0	0
31	Structures and stability of GaN/Ga ₂ O ₃ interfaces: a first-principles study. Japanese Journal of Applied Physics, 0, , .	1.5	Ο
32	Reaction of nitrous oxide and ammonia molecules at 4H-SiC/SiO <mml:math xmlns:mml="http://www.w3.org/1998/Math/MathML" altimg="si1.svg"><mml:msub><mml:mrow /><mml:mn>2</mml:mn></mml:mrow </mml:msub> interface: An ab initio study. Surface Science, 2022, 723, 122102.</mml:math 	1.9	0